



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

#9/EXT  
7/22/02  
VLS

In re application of:

Liming Tsau

Appl. No. 09/753,664

Filed: January 4, 2001

For: **High Density Metal Capacitor  
Using Via Etch Stopping Layer as  
Field Dielectric in Dual-  
Damascene Interconnect Process**

Confirmation No. 1902

Art Unit: 2823

Examiner: Brairton, Scott A.

Atty. Docket: 1875.0230000

TECHNICAL STAFF  
JUL 23 2002

**Petition For Extension of Time Under 37 C.F.R. § 1.136(a)(1)**

Commissioner for Patents  
Washington, D.C. 20231

Sir:

It is hereby requested that the period for replying to the outstanding Office Action be extended one (1) month from June 27, 2002 to July 27, 2002 by the filing of this Petition and fee payment.

The petition fee (37 C.F.R. § 1.17(a)) is believed to be \$110.00 for a one (1) month extension for a large entity. Fee payment is provided in our accompanying Check No. 35729 However, if extensions of time under 37 C.F.R. § 1.136 other than those provided herewith are required to prevent abandonment of the present patent application, then such extensions of time are hereby petitioned.

The U.S. Patent and Trademark Office is hereby authorized to charge any fee deficiency, or credit any overpayment, to our Deposit Account No. 19-0036.

Respectfully submitted,

STERNE, KESSLER, GOLDSTEIN & FOX P.L.L.C.

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Date: 7/3/02.

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